Amendments to the Claims

1. (Previously presented) A method of forming a metal complex of formula $M(Ar^1Ar^2)_nL$ comprising the step of reacting a compound of formula (I) with a bidentate ligand L:

$$\begin{pmatrix} Ar^1 \\ Ar^2 \end{pmatrix}_n \begin{pmatrix} Hal \\ Hal \\ M \begin{pmatrix} Ar^1 \\ Ar^2 \end{pmatrix}_n$$

wherein Ar¹ and Ar² are each independently an optionally substituted aryl or heteroaryl; Ar¹-Ar² forms at least one carbon-M bond by reaction of M with a carbanion of Ar¹-Ar²; L is a compound of formula Ar¹-Ar²; M is iridium, rhodium, platinum or palladium; Hal is a halogen; and n is a number form 1-3 having a value necessary to satisfy the valency of metal M,

in the presence of an enabling ligand that is capable of breaking the halogen bridge of the compound of formula (I).

- 2. (Previously presented) A method according to claim 1 wherein Hal is bromine, chlorine or iodine.
- 3. (Previously presented) A method according to claim 1 wherein Ar^1 -Ar² is phenylpyridine.
- 4. (Previously presented) A method according to claim 1 wherein Ar^1 Ar^2 and L are the same.
- 5. (Withdrawn) A method according to claim 1 wherein Ar¹-Ar² and L are different.
- 6. (Previously presented) A method according to claim 1 wherein the enabling ligand is a monodentate ligand.

- 7. (Previously presented) A method according to claim 6 wherein the monodentate ligand is selected from the group consisting of optionally substituted pyridine and triarylphosphine.
- 8. (Previously presented) A method according to claim 1 wherein the enabling ligand is a bidentate ligand of formula (IIb):

wherein each R is independently selected from the group consisting of H and a substituent.

- 9. (Previously presented) A method according to claim 8 comprising forming the ligand of formula (IIb) by treating a corresponding protonated compound with a metal-free base.
- 10. (Previously presented) A method according to claim 8 wherein each R is hydrogen.
- 11. (Previously presented) A method of forming a metal complex of formula M(Ar¹Ar²)_nL comprising a first step of preparing a compound of formula (I) by reacting a compound of formula M(Hal)_m with a compound of Ar¹-Ar² and a second step according to claim 1, wherein m is a number necessary to satisfy the valency of M, comprising performing the first and second steps in a one-pot process.

- 12. (Previously presented) A method according to claim 1 comprising performing reaction in a protic solvent.
- 13. (Previously presented) A method of forming a metal complex comprising:
- a) a first step of reacting a compound of formula $M(Hal)_m$ with a compound of formula Ar^1-Ar^2 to form a compound of formula (I):

$$\begin{pmatrix} Ar^1 \\ Ar^2 \end{pmatrix}_n \begin{pmatrix} Hal \\ Hal \\ M \end{pmatrix} \begin{pmatrix} Ar^1 \\ Ar^2 \end{pmatrix}_n$$

and

b) a second step of reacting the compound of formula (I) with a reactive ligand that is capable of breaking the halogen bridge of the compound of formula (I)

wherein Ar¹ and Ar² are each independently an optionally substituted aryl or heteroaryl; Ar¹-Ar² forms at least one carbon-M bond by reaction of M with a carbanion of Ar¹-Ar²; L is a compound of formula Ar¹-Ar²; M is iridium, rhodium, platinum or palladium; Hal is a halogen; m is a number from 2-8 and n is a number from 1-3, m and n each having a value necessary to satisfy the valency of metal M, wherein the first and second steps are performed in a one-pot process.

14. (Previously presented) A method of forming a metal complex comprising the step of reacting a metal halide with a ligand of formula (II):

wherein each R is H or a substituent,

in the presence of a metal-free base of sufficient strength to deprotonate the compound of formula (II).

- 15. (Previously presented) A method according to claim 1 wherein Hal is chlorine.
- 16. (Previously presented) A method according to claim 9 wherein each R is hydrogen.
- 17. (Previously presented) A method according to claim 12 wherein the protic solvent is ethylene glycol.